
Symposium (Oral) | Symposium | What is next killer application after display? Leading edge technology of oxide semiconductor

[17p-E302-1~8]What is next killer application after display? Leading edge technology of oxide semiconductor

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Fri. Mar 17, 2023 1:30 PM - 5:55 PM E302 (Building No. 12)

△ : Presentation by Applicant for JSAP Young Scientists Presentation Award

▲ : English Presentation

▼ : Both of Above

No Mark : None of Above

4:55 PM - 5:55 PM

[17p-E302-8]Panel Discussion

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